L Number	Hits	Search Text	DB	Time stamp
1	3676	(remov$3 same oxide) same ((hydrofluoric near acid or "HF") near solution)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 19:51
2	134	((remov$3 same oxide) same ((hydrofluoric near acid or "HF") near solution)) same (percent or "%")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 19:51
3	62	(((remov$3 same oxide) same ((hydrofluoric near acid or "HF") near solution)) same (percent or "%")) and @pd<20000128	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 19:58
4	2	((((remov$3 same oxide) same ((hydrofluoric near acid or "HF") near solution)) same (percent or "%")) and @pd<20000128) and (chemical near oxide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 19:54
5	12	((((remov$3 same oxide) same ((hydrofluoric near acid or "HF") near solution)) same (percent or "%")) and @pd<20000128) and (vapor$3 same (hydrofluoric or "HF"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 19:59
6	2	((((remov$3 same oxide) same ((hydrofluoric near acid or "HF") near solution)) same (percent or "%")) and @pd<20000128) and (vapor$3 near5 (hydrofluoric or "HF"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 19:59
-	1188	(remov$3 or stripp$3 or clean$3) same ((hydrofluoric near acid or "HF") near5 vapor$2)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 19:46
-	63	((remov$3 or stripp$3 or clean$3) same ((hydrofluoric near acid or "HF") near5 vapor$2)) same transfer$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 18:48
-	28	(((remov$3 or stripp$3 or clean$3) same ((hydrofluoric near acid or "HF") near5 vapor$2)) same transfer$3) and @pd<20000128	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 18:50
-	24	((((remov$3 or stripp$3 or clean$3) same ((hydrofluoric near acid or "HF") near5 vapor$2)) same transfer$3) and @pd<20000128) and wafer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 18:50
-	2	("6178660").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/22 19:43